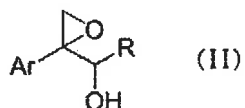


ABSTRACT

A compound represented by formula (II):

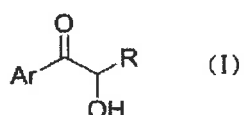


(where Ar represents a phenyl group optionally substituted by 1 to 3 substituents selected from the group consisting of a halogen atom and a trifluoromethyl group, and R represents a hydrogen atom or an alkyl group having 1 to 12 carbon atoms)

is produced by

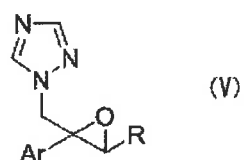
step A: reacting trimethyl oxosulfonium salt or trimethyl sulfonium salt with a base in a solvent, and removing the resulting solid to obtain a trimethyl oxosulfonium ylide solution or a trimethyl sulfonium ylide solution; and

step B: reacting a compound represented by formula (I):



and the solution obtained in step A,

and the compound represented by formula (II) can be derived to a compound represented by formula (V):



that is useful for production of an antifungal agent.